



## Advanced Oxidation Process for Wastewater Treatment

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### Message from the Guest Editors

This Special Issue on “Advanced Oxidation Process for Wastewater Treatment” seeks original research and review articles on the latest advances of Fenton and Fenton-like oxidation, photocatalytic oxidation, electrocatalytic oxidation, ozone oxidation, persulfate oxidation, ultrasonic oxidation, and supercritical oxidation. This Issue aims to promote new highly effective and cost-efficient AOPs for wastewater treatment. Topics include, but are not limited to:

1. Efficient AOPs for persistent organic pollutants;
2. Advanced functional materials for oxidation processes;
3. In situ characterization and mechanism investigation for AOPs;
4. Sustainability assessment of AOPs.





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## Message from the Editor-in-Chief

*Processes* (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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